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### INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Page **1** of **2**

Atty. Dkt. No.	M#	Client Ref.
	0305376	P-0362.010-US
Applicant: VAN BILSEN et al.		
Appn. No.: 10/665,404		
Filing Date: September 22, 2003		
Examiner:		Group Art Unit: 2881

U.S. PATENT DOCUMENTS							
Examiner's Initials*		Document Number	Date MM/YYYY	Name (Family Name of First Inventor)	Class	Sub Class	Filing Date (if appropriate)
JL	AR	4,037,969	07/1977	FELDMAN et al.			
	BR	4,236,805	04/1982	FELDMAN et al. 4326805			
	CR	4,251,160	02/1981	BOUWHUIS et al.			
	DR	4,355,892	10/1982	MAYER et al.			
	ER	4,398,824	08/1983	FELDMAN et al.			
	FR	4,514,858	04/1985	NOVAK			
	GR	4,540,277	09/1985	MAYER et al.			
	HR	4,614,432	09/1986	KUNIYOSHI et al.			
	IR	4,690,529	09/1987	SUGIYAMA et al.			
	JR	4,710,026	12/1987	MAGOME et al.			
	KR	4,748,333	05/1988	MIZUTANI et al.			
	LR	4,778,275	10/1988	VAN DEN BRINK et al.			
	MR	4,814,829	03/1989	KOSUGI et al.			
	NR	4,828,392	05/1989	NOMURA et al.			
	OR	4,857,744	08/1989	KATAOKA et al.			
	PR	4,861,162	08/1989	INA			
	QR	4,870,452	09/1989	TANIMOTO et al.			
	RR	4,952,970	08/1990	SUZUKI et al.			
	SR	5,100,237	03/1992	WITTEKOEK et al.			
▼	TR	5,114,236	05/1992	MATSUGU et al.			
	UR	5,118,953	06/1992	OTA et al.			

FOREIGN PATENT DOCUMENTS						English Abstract	Translation Readily Available			
		Document Number	Date MM/YYYY	Country	Inventor Name		Enclosed	No	Enclose	No
JL	VR	11-329914	11/1999	Japan	SAKO TAKASHI		X			X
WR										
XR										
YR										

### OTHER (Including in this order Author, Title, Periodical Name, Date, Pertinent Pages, etc.)

ZR	Markle, D. A., "Submicron 1:1 Optical Lithography", Semi-conductor International, pp. 173-142, May 1986.	X
AAR		
BBR		
CCR		

Examiner /John Lee/ (02/18/2007)	Date Considered:
*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.	